| Electronic Patent Application Fee Transmittal | | | | | | | |
|---|---|----------|----------|--------|-------------------------|--|--|
| Application Number: | 08893917 | | | | | | |
| Filing Date: | 11-Jul-1997 | | | | | | |
| Title of Invention: | REMOTE PLASMA CLEANING SOURCE HAVING REDUCED REACTIVITY WITH A SUBSTRATE PROCESSING CHAMBER | | | | | | |
| First Named Inventor/Applicant Name: | KARL A. LITTAU | | | | | | |
| Filer: | Patrick Maurice Boucher/Nina L. McNeill | | | | | | |
| Attorney Docket Number: | AM2119/T2130 | | | | | | |
| Filed as Large Entity | | | | | | | |
| Utility Filing Fees | | | | | | | |
| Description | | Fee Code | Quantity | Amount | Sub-Total in USD(\$) | | |
| Basic Filing: | | | | | | | |
| Pages: | | | | | | | |
| Claims: | | | | | | | |
| Miscellaneous-Filing: | | | | | | | |
| Petition: | | | | | | | |
| Patent-Appeals-and-Interference: | | | | | | | |
| Post-Allowance-and-Post-Issuance: | | | | | | | |
| Extension-of-Time: | | | | | | | |
| Extension - 3 months with \$0 paid | | 1253 | 1 | 1020 | 1020 | | |

| Description | Fee Code | Quantity | Amount | Sub-Total in USD(\$) |
|----------------|-------------------|----------|--------|-------------------------|
| Miscellaneous: | | | | |
| | Total in USD (\$) | | | 1020 |